



Attorney's Docket No.: 042390P11354

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)

Liang, Ted et al.)

U.S. Serial No: 09/895,511)

Filed: June 29, 2001)

For: MASK REPAIR WITH
ELECTRON BEAM-INDUCED
CHEMICAL ETCHING)

Assistant Commissioner for Patents
and Trademarks
Washington, D.C. 20231

Examiner: Zervignon, Rudy #8

Art Unit: 1763

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(37 c.f.r. § 1.8(a))

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on Teresa Edulandy

February 3, 2003
Date

FORMAL DRAWINGS SUBMISSION

Enclosed herewith for submission in the United States Patent and Trademark Office are
three (3) sheets of formal drawings for the patent application referenced above.

If there are any further charges please charge them to Deposit Account No. 02-2666. A
duplicate of this sheet is enclosed for that purpose.

Respectfully submitted,

BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Dated: February 3, 2003

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